



PATENT APPLICATION

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER ART UNIT 2826**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Akira SAKAI et al.

Group Art Unit: 2826

Application No.: 10/807,235

Examiner: E. PERT

Filed: March 24, 2004

Docket No.: 119232

For: METHOD FOR FABRICATING A METALLIC OXIDE OF HIGH DIELECTRIC
CONSTANT, METALLIC OXIDE OF HIGH DIELECTRIC CONSTANT, GATE
INSULATING FILM AND SEMICONDUCTOR ELEMENT

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the May 23, 2005 Office Action, please consider the following:

Amendments to the Claims as reflected in the listing of claims; and

Remarks.